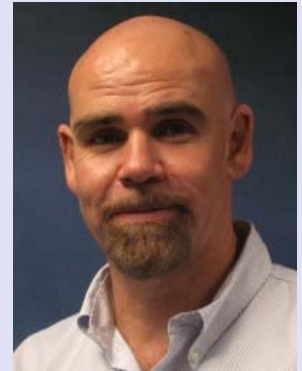




Title:

**Nonlinear refraction and absorption:
Mechanisms, Characterization and Applications**

Prof. David J. Hagan
University of Central Florida



2015/11/19 (Thu.) AM 10:00-12:00

國立成功大學 光電科學與工程學系
綜合大樓 48418 室 (4F)

About the speaker:

Biography:

David J. Hagan received his PhD degree in Physics at Heriot-Watt University, Edinburgh, Scotland in 1985. After a brief spell as research scientist at the University of North Texas, he moved to UCF in 1987 as a founding member of the CREOL faculty. He is currently Professor of Optics and Physics and also serves as Associate Dean for Academic Programs. He is currently Editor-in-Chief of the OSA journal, Optical Materials Express. His current research interests include nonlinear optical materials, especially semiconductors and organics, applications of extremely nondegenerate nonlinear optics, and techniques for nonlinear optical characterization and spectroscopy. Dr. Hagan is a Fellow of OSA.

Sponsored by:
Department of Photonics, NCKU

